CLAIMS

SUBA,

1. A process for carrying out impregnation and/or for preparing a coating which gives release and is leaktight employed at the engine block/cylinder head interface of engines and applied in particular to sheet gaskets, in particular cylinder head gaskets,

characterized in that it consists essentially:

1 - in employing a silicone composition comprising:

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-A- 100 parts by weight of at least one polyorganosiloxane (POS) crosslinkable by the cationic and/or radical route and via crosslinking functional groups (CFGs), these CFGs being identical to or

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different from one another and being chosen from those comprising at least one functional unit of heterocyclic nature having one or more electron-

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donating atoms and/or from those which are ethylenically unsaturated and

substituted by at least one electron-

donating atom which enhances the

basicity of the π system;

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-B- from 0.01 to 10 parts by weight of at

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least one initiator salt (PI) formed by a borate of an onium of an element from groups 15 to 17 of the Periodic Classification [Chem. & Eng. News, Vol. 63, No. 5, 26 of February 4, 1985] or of an organometallic complex of an element from groups 4 to 10 of the Periodic Classification (same reference),

- the cationic entity of said borate being chosen from:
- (1) onium salts of formula (I):

$$[(R^1)_n - A - (R^2)_m]^+$$
 (I)

in which formula:

- A represents an element from groups
 15 to 17;
- R¹ represents a C₁-C₂₀ carbocyclic or heterocyclic aryl radical, it being possible for said heterocyclic radical to comprise nitrogen or sulfur as heteroelements;
- R^2 represents R^1 or a linear or branched C_1 - C_{30} alkyl or alkenyl radical; said R^1 and R^2 radicals

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optionally being substituted by a

 C_1-C_{25} alkoxy, C_1-C_{25} alkyl, nitro, chloro, bromo, cyano, carboxy, ester or mercapto group, 5 ablan is an integer ranging from 1 to $\sqrt{+1}$, v being the valency of the element A, m is an integer ranging from 0 to v - 1, with n + m = v + 1, HOOOGGG GWHOON 10 (2) - the oxoisothiochromanium salts having the formula: (11) where the R^6 radical represents a linear or 15 branched C1-C20 alkyl radical; (3) - sulfonium salts where the cationic entity comprises: \rightarrow 3.1. at least one polysulfonium species of 20 formula III.1

in which:

the Ar¹ symbols, which can be identical to or different from one another, each represent a monovalent phenyl or naphthyl radical optionally substituted with one or more radicals chosen from:

a linear or branched C₁-C₁₂ alkyl radical, a linear or branched C₁-C₁₂ alkoxy radical, a halogen atom, an -OH group, a -COOH group, a -COO-alkyl ester group, where the alkyl part is a linear or branched C₁-C₁₂ residue, and a group of formula -Y⁴-Ar², where the Y⁴ and Ar² symbols have the meanings given immediately below,

the Ar^2 symbols, which can be identical to or different from one another or Ar^1 , each represent a monovalent phenyl or naphthyl radical optionally substituted with one or more radicals chosen from: a linear or branched C_1 - C_{12} alkyl radical, a linear or branched C_1 - C_{12} alkoxy radical, a halogen atom, an -OH group, a -COOH group or a -COO-alkyl ester group, where the alkyl part is a linear or branched C_1 - C_{12} residue,

the Ar³ symbols, which can be identical to or different from one another, each represent a divalent phenylene or naphthylene radical optionally substituted with one or more radicals

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chosen from: a linear or branched C_1 - C_{12} alkyl radical, a linear or branched C_1 - C_{12} alkoxy radical, a halogen atom, an -OH group, a -COOH group or a -COO-alkyl ester group, where the alkyl part is a linear or branched C_1 - C_{12} residue, t is an integer equal to 0 or 1,

with the add tional conditions according to which:

+ when t = 0, the Y symbol is then a Y¹ monovalent radical representing the group of formula:

where the Ar¹ and Ar² symbols have the meanings given above,

+ when t = 1:

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* on the one hand, the Y symbol is then a divalent radical having the following meanings Y^2 to Y^4 :

• Y²: a group of formula:



where the ${\rm Ar}^2$ symbol has the meanings given above,

• Y3: a single valendy bond,

• Y4: a divalent residue chosen from:

-0-, -g-, -c-

a linear or branched C_1-C_{12} alkylene residue and a residue of formula $-Si\left(CH_3\right){}_2O-$,

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where the Y symbol represents Y³ or Y⁴,
the Ar¹ and Ar² (terminal) radicals have,
in addition to the meanings given above,
the possibility of being connected to
one another via the Y' residue

consisting in Y'¹, a single valency bond,
or in Y'², a divalent residue chosen from
the residues cited with respect to the
definition of Y¹, which is inserted
between the carbon atoms, facing each
other, situated on each aromatic ring in
the ortho position with respect to the
carbon atom directly bonded to the S⁺
cation;

⇒ 3.2. and/or at least one monosulfonium species having a single S⁺ cationic center per mole of cation and consisting, in the majority of cases, in species of formula:

$$Ar^{1} - S - Ar^{1} \qquad (III.2)$$

25 in which Ar^1 and Ar^2 have the meanings given above with

respect to the formula (III.1), including the possibility of connecting directly between them only one of the Ar¹ radicals to Ar² according to the way indicated above with respect to the definition of the additional condition in force when t=1 in the formula (II) involving the Y' residue;

(4) organometallic salts of formula (IV):

 $(L^1L^2L^3M)^{q+}$ (IV)

in which formula:

• M represents a metal from group 4 to 10,

• L¹ represents 1 ligand bonded to the metal M via π electrons, which ligand is chosen from η^3 -alkyl, η^5 -cyclopendadienyl and η^7 -cycloheptratrienyl ligands and η^6 -aromatic compounds chosen from optionally substituted η^6 -benzene ligands and compounds having from 2 to 4 condensed rings, each ring being capable of contributing to the valency layer of the metal M via 3 to 8 π electrons,

• L^2 represents a ligand bonded to the metal M via π electrons, which ligand is chosen from η^7 -cycloheptatrienyl ligands and η^6 -aromatic compounds chosen from optionally substituted η^6 -benzene ligands and compounds having from 2 to 4 condensed rings, each ring being capable of contributing to the valency layer of the

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metal M via 6 or 7 π electrons,

• L³ represents from 0 to 3 identical or different ligands bonded to the metal M via σ electrons, which ligand(s) is (are) chosen from CO and NO2[†]; the total electronic charge q of the complex to which L¹, L² and L³ and the ionic charge of the metal M contribute being positive and equal to 1 or 2;

the aniohic entity [lacuna] borate having the formula:

 $[BX_a/R_b]^-$

in which formula:

- a and b are integers ranging from 0 to 3 for a and from 1 to 4 for b, with

a + b = 4,

- the X symbols represent:

* a halogen atom with a = 0 to 3,

* an OH functional group with a = 0 to 2,

- the R symbols are identical or different and represent:

a phenyl radical substituted by at least one electron-withdrawing group and/or by at least 2 halogen atoms, this being when the cationic entity is an onium of an element from groups 15 to 17,

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a phenyl radical substituted by at least

one electron-withdrawing element or group, this being when the cationic entity is an organometallic complex of 5 an element from groups 4 to 10, and aryl radical comprising at least two aromatic nuclei, which is optionally substituted by at least one electronwithdrawing element or group, whatever 10 the cationic entity; 1 to 50 parts by weight of at least one reactive diluent consisting in a nonorganosilicon organosilicon or organic compound comprising, in its structure, at least one CFG as defined above and optionally at least one secondary functional group (SFG) other than a CFG but capable of reacting chemically with a CFG; 0 to 10 parts by weight of at least one 20 -Dpigment; 0 to 100 parts by weight of a filler of inorganic nature; -F- 0 to 10 parts by weight of at least one 25 photosensitizer; -G- 0 to 10^{-2} part by weight of a stabilizer

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consisting in at least one stabilizing amine agent,

- -H- 0 to 5 parts by weight of an adhesion promoter;
- 2 in applying this composition to a support (cylinder head sheet gasket or cylinder head/engine block interface), and
- 3 in crosslinking the applied composition by <u>photochemical</u> and/or thermal activation and/or under 10 an electron beam.
 - 2. The process as claimed in claim 1, characterized in that the support is a metal cylinder head gasket.
 - 3. The process as claimed in claim 2, characterized in that the support is a metal multilayer cylinder head gasket and in that a coating is formed on at least one of the faces of at least one of the layers composing the metal multilayer cylinder head gasket.
- 4. The process as claimed in any one of

 20 claims 1 to 3, characterized in that the functional
 units included in the CFG groups are selected from the
 group of following units:
 - an ethylenically unsaturated and activated functional group,
- 25 epoxide,
 - oxethane,

- and their mixtures,

and in that the functional units included in the optional SFG groups are selected from the group of following units:

- 5 hydroxyl,
 - alkoxy,
 - carboxxl,
 - and their mixtures.
- 5. The process as claimed in any one of

 10 claims 1 to 4, characterized in that the POSs A are
 epoxysilicones and/or vinyl ether silicones which are:

 → either linear or substantially linear and composed of
 units of formula (I), terminated by units of formula

 (II),
 - → or cyclic and composed of units of formula (II):

$$\begin{array}{c|c}
 & R^3 \\
 & \downarrow \\
 & \downarrow \\
 & Z
\end{array}$$
(I)
$$\begin{array}{c|c}
 & R^3 \\
 & 2 - \stackrel{1}{s_i} - 0 - \\
 & \stackrel{1}{R}^3
\end{array}$$
(II)

in which formulae:

- 20 the R³ symbols are alike or different and represent:
 - either a hydroxyl radical,
 - or a linear or branched C_1 C_{18} alkyl radical which is optionally substituted by one or more halogens and/or a hydroxyl radical,
- 25 or a C_2 - C_8 alkenyl radical,

- or an optionally substituted $C_5 C_8$ cycloalkyl radical,
- or an aryl or aralkyl radical which is optionally substituted by halogens and/or alkoxyls,
- the Z symbols are alike or different and represent:
 - either the R³ radical,

to a CFG group.

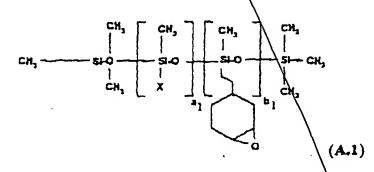
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or a CFG group corresponding to an epoxide or vinyl ether residue connected to the silicon via a divalent radical comprising from 2 to 20 carbon atoms and optionally comprising a heteroatom, at least one of the Z symbols corresponding

6. The process as claimed in any one of claims 1 to 5, characterized in that the POSs A are epoxysilicones of formula (A.1), (A.2) and (A.3):



20 with X = CH₃; phenyl; C₅-C₈ cycloalkyl; C₁-C₁₈ alkyl; C₂-C₈ alkenyl; -OH; H; -CH₂-CH₂-CH₂-OH; -CH₂-CF₃ or -(CH₂)_n-CF₃, n = 1 to 20;

- a_1 , a_2 , $b_{\dot{1}}^{\dot{1}}$ and b_2 being defined as follows in these formulae (A.1) and (A.2)

 $1 \leq a_1, a_2$

 $1 \le b_1, b_2$

- a_2 and b_2 being = 0 in the formula (A.2) to give the epoxidized disilexane (A.3).

The process as claimed in any one of 7. claims 1 to 6, characterized in that the reactive diluent(s) C is (are \ chosen:

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 \rightarrow from the honorganosilicon organic compounds (C_1) possessing CFG + optionally SFG reactive groups having the following formulae:

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$$(C_1)$$
 (C_1)
 $(C_1$

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 \rightarrow and/or from the organosilicon compounds (C₂) possessing CFG + optionally SFG reactive groups having the following formulae:

with
$$R^7 = C_1 - C_{10}$$
 alkyl,
$$(C_2')$$

$$(C_2')$$

with R^8 independently representing a $C_1\text{-}C_{10}$ alkyl.

- 8. The process as claimed in any one of claims 1 to 7, characterized in that the diluent (C) exhibits a boiling point B.p. ≥ 100°C at standard
 15 atmospheric pressure and a viscosity at 25°C η ≤ 100 mPa.s.
 - 9. The process as claimed in any one of claims 1 to 8, characterized in that, prior to stage 1, the support to be coated is covered using an adhesion primer of the type of those comprising at least one compound chosen from the group consisting of:
 - alkoxylated silanes carrying at least one ethylenic unsaturation and/or at least one epoxide

- (meth)acrylates,
- metal chelates and/or alkoxides,
- crosslinkable silicone compositions and compositions which are precursors of silicone elastomers.

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